

Development of metal-oxide nanostructures for application in optoelectronic devices

Project Leader

LI Chaoyang, Dr. Eng.

Professor

Center for Nanotechnology, Research Institute & Electronic and Photonic Systems Engineering

Faculty Members Involved in this Project

None.

Objective

We are working on the synthesis of thin film and nanostructures based on metal-oxide-semiconductor materials such as ZnO and TiO₂, using various techniques including radio frequency sputtering, mist CVD, spin-coating, solution and hydrogen-thermal methods. It is anticipated that well-aligned nanostructures can be designed for applications including photovoltaic devices, sensors, phosphor, and antibacterial agents. We are seeking to build nanostructures that are high-performance, highly efficient, low-cost, and environmentally friendly.

Project Outline

- 1) Synthesis and evaluation of nanomaterial and nanostructures.
 - a) Deposition of thin film using radio-frequency sputtering, solution or mist CVD methods.
 - b) Synthesis of nanostructures by annealing, solution, or hydrogen thermal method.
- 2) Device fabrication and evaluation.
 - a) Fabrication of photovoltaic devices, for example dye-sensitized solar cells, using ZnO nanostructures with or without TiO₂ serving as electrodes.
 - b) Fabrication of a nanostructured thin film phosphor for use in displays or lighting.
 - c) Evaluation of antibacterial activity for the obtained nanostructures.

Required skills or Knowledge

- 1) Study or research background in material science (particularly oxide-metal semiconductor material), optoelectronics, physics, and chemical physics.
- 2) Experience in the fabrication and evaluation of nano-scale materials.
- 3) Good English conversation and academic writing skills.

References

- 1) Thickness of ITO thin film influences on fabricating ZnO nanorods applying for dye-sensitized solar cell, X. Li, C. Li et al, *Composites Part B: Engineering*, 74, 147-152 (2015).
- 2) Influence of substrates on formation of zinc oxide nanostructures by a novel reducing annealing method, X. Li, C. Li, et al, *Nanoscience and Nanotechnology Letters*, 5, 1-7(2013).

3) Well-arrayed ZnO nanostructures formed by multi-annealing processes at low temperature, D. Wang, C. Li et al, *Physica Status Solidi C*, 9,194-197 (2012).

Contact information

E-mail: li.chaoyang@kochi-tech.ac.jp